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Functional Thin Film and Plasma Electrolytic Oxidation

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Deadline for manuscript submissions: **30 June 2024**

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Message from the Guest Editors

For this Special Issue, original research articles and reviews are welcome. Research areas may include (but are not limited to) the following:

- Fundamental insights into the thin film fabrication process;
- Integration of thin film technology with sustainable green processes;
- Simulation techniques, software or other means for modelling and simulation in thin film applications;
- Thin film devices including innovative concepts for fabrication, processes and application in renewable energy sector;
- Medical applications of thin films.











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Message from the Editor-in-Chief

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